



JPW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Akira SAKAI et al.

Group Art Unit: 2829

Application No.: 10/807,235

Examiner: E. Pert

Filed: March 24, 2004

Docket No.: 119232

For: METHOD FOR FABRICATING A METALLIC OXIDE OF HIGH DIELECTRIC
CONSTANT, METALLIC OXIDE OF HIGH DIELECTRIC CONSTANT, GATE
INSULATING FILM AND SEMICONDUCTOR ELEMENT

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the September 22, 2004 Office Action, please consider the following:

Amendments to the Specification;

Amendments to the Claims as reflected in the listing of claims; and

Remarks.